

## CLAIMS

1. A method of manufacturing a plasma display panel in which the plasma display panel is held by a substrate holder for deposition, wherein the substrate holder is configured with a plurality of frames, the substrate is held by its periphery with at least one of the frames, and the frame holding the substrate has a protrusion extending to a non-deposition face of the substrate held in such a way as to surround the substrate.
2. The method of manufacturing a plasma display panel as defined in Claim 1, wherein a height of the protrusion is between 1 mm and 100 mm from the non-deposition face of the substrate.
3. The method of manufacturing a plasma display panel as defined in Claim 1, the frame comprising holding means including support means for supporting the substrate from underneath and positioning means for positioning the substrate in a planar direction, wherein the substrate is held by fitting the substrate to the positioning means and placing the substrate on the support means.
4. A substrate holder for a plasma display panel used for deposition on a substrate of the plasma display panel, the substrate holder being configured with a plurality of frames, the substrate being held by its periphery with at least one of the frames, and the frame holding the substrate being provided with a protrusion extending to a non-deposition face of the substrate held in such a way as to surround the substrate.

5. The substrate holder for a plasma display panel as defined in Claim 4, wherein a height of the protrusion is between 1 mm and 100 mm from the non-deposition face of the substrate.

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6. The substrate holder for a plasma display panel as defined in Claim 4, the frame comprising holding means including support means for supporting the substrate from underneath and positioning means for positioning the substrate in a planar direction, wherein the substrate is held by fitting the substrate to the positioning means and placing the substrate on the support means.

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